

FIR-VUV Ellipsometry on $B_xGa_{1-x}As$ and GaN_yAs_{1-y}



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Motivation

- $GaN_{1-y}As_y$ and $B_xGa_{1-x}As$ differ fundamentally in their bonding properties, i. e., B-As is almost purely covalent whereas Ga-N bond has large ionic contribution
- Influence of ionicities on bandstructure and phonon properties
- $In_xGa_{1-x}N_yAs_{1-y}$ and $B_xGa_{1-x}In_yAs$ as new materials for 1.3-1.55 μm laser diodes and solar cells
- Effect of hydrogen on bandstructure of $In_xGa_{1-x}N_yAs_{1-y}$?

$B_xGa_{1-x}As$

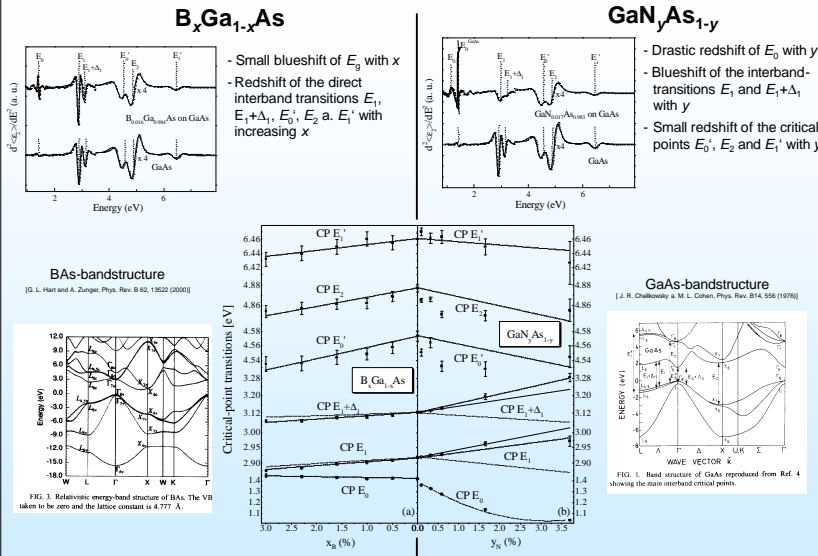
- $a_0^{BAs} = 4.777 \text{ \AA} \rightarrow \Delta a/a = 16\%$
- Ionicity of the B-As bond: $f_i^{BAs} = 0.002$
- BAs-like phonon could not be detected using IR ellipsometry or IR transmission due to low ionicity of B-As bond
- BAs-phonon is Raman-active
- Perturbation potential of B in GaAs mainly due to strain
- Weaker than perturbation potential of N in GaAs
- Small bowing parameters of all detected critical-point transitions ($E_0, E_1, E_1+\Delta_1, E_0', E_2$ and E_1')
- $B_xGa_{1-x}As$ behaves like a „normal alloy“!

Conclusion

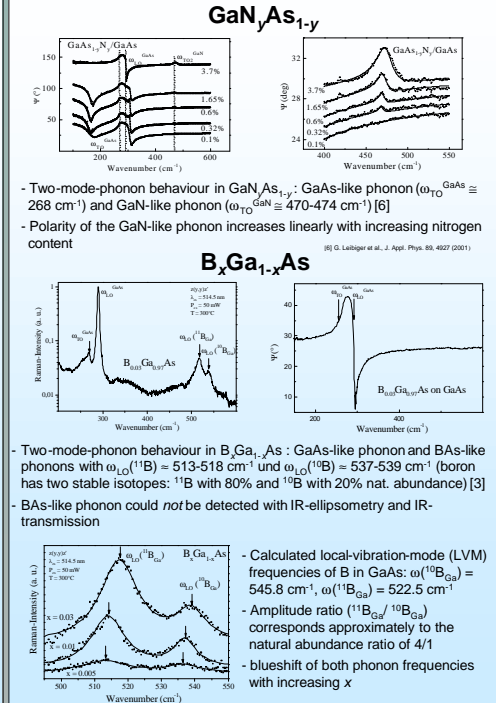
GaN_yAs_{1-y}

- $a_0^{B-GaN} = 4.52 \text{ \AA} \rightarrow \Delta a/a = 20\%$
- Ionicity of the Ga-N bond: $f_i^{GaN} = 0.500$
- GaN-like phonon is infrared-active (high ionicity of Ga-N bond)
- Strong, shortranging perturbation potential of N in GaAs due to strain and the large ionicity of the Ga-N bond
- Drastic redshift of E_0 with increasing y
- Redshift can be neutralized by Hydrogen implantation
- Moderate shift of $E_1, E_1+\Delta_1, E_0', E_2$ and E_1' with y → perturbation of the band-structure concentrated on the Γ -point of the Brillouin zone
- GaN_yAs_{1-y} does not behave like a „normal alloy“!

Bandstructure of $B_xGa_{1-x}As$ and GaN_yAs_{1-y}



GaN- and BAs-like Phonons



Ionicities of the bonds

	B	C	N
Electronegativity	2.01	2.55	3.07
Atomic radius	0.853 Å	0.77 Å	0.719 Å
	Ga	Ge	As
Electronegativity	1.82	2.02	2.20
Atomic radius	1.225 Å	1.22 Å	1.225 Å
	In	Sn	Sb
Electronegativity	1.9	2.0	2.0
Atomic radius	1.43 Å	1.4 Å	1.4 Å

- Phillips/Van Vechten model: $E_g^2 = E_c^2 + C^2$ (E_c band gap, C ionic and E_c homopolar contribution to E_g) [7,8]
- Ionicity of a bond: $f_i = C^2/E_g^2$ [7,8]

B-As	Ga-As	Ga-N
$f_i = 0.002$	$f_i = 0.310$	$f_i = 0.500$

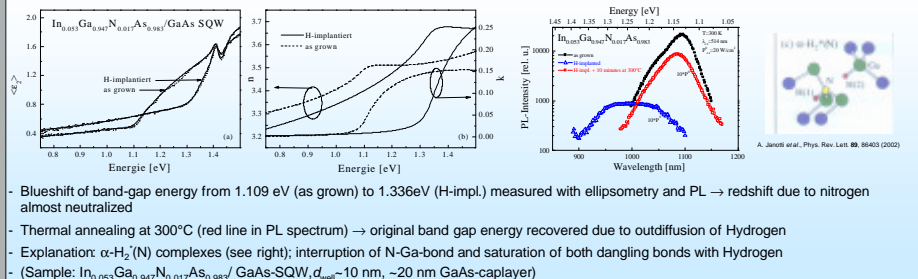
Ⓢ B-As bond is almost purely covalent, whereas the Ga-N bond has a large ionic contribution

[7] J. A. Van Vechten, Phys. Rev. 187, 1007 (1969).
[8] J. C. Phillips, Bonds and Bands in Semiconductors, Academic Press, New York (1973).

Acknowledgement

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Hydrogen Implantation in $In_xGa_{1-x}N_yAs_{1-y}$



Samples

MOVPE (metalloorganic vapor-phase epitaxy)
- GaN_yAs_{1-y} : $y = 0 \dots 3.7\%$, $T_G = 525 \text{ }^\circ\text{C}$, Precursor: TBAS, DMHy, TMGa

- $B_xGa_{1-x}As$:
 $x = 0 \dots 3\%$, $T_G = 550-600 \text{ }^\circ\text{C}$, Precursor: AsH_3 , TEB, TMGa

Experiment

- **Ellipsometry**: far- and mid-ir range ($100 \text{ cm}^{-1} \leq \omega \leq 600 \text{ cm}^{-1}$) and near-ir-VUV range ($0.75 \text{ eV} \leq E \leq 8 \text{ eV}$), $T = 300 \text{ K}$
- **Raman**: Dilor XY 800 in macroconfiguration; $\lambda_{exc} = 514.5 \text{ nm}$, $P_{exc} = 50 \text{ mW}$, backscattering-configuration $z(y, y)z'$, $T = 300 \text{ K}$
- **Photoluminescence (PL)**: $\lambda_{exc} = 514.5 \text{ nm}$, $T = 300 \text{ K}$
- **H-implantation**: Kaufmann-source, $E_{ion} \sim 300 \text{ eV}$, $T_{sample} \sim 300 \text{ }^\circ\text{C}$, dose $\sim 4.4 \cdot 10^{17} \text{ ions/cm}^2$

Model Dielectric Function

- **Polar phonons**: $\epsilon^{(P)}(\omega) = \epsilon_{\infty} + \sum_{j=1}^N \frac{f_j \omega_j^2 - \omega^2 - i\gamma_j \omega}{\omega_j^2 - \omega^2 - i\gamma_j \omega}$ here: no anharmonic interaction: $\gamma_{LO} = \gamma_{TO}$
- **Free carriers**: $\epsilon^{(FC)}(\omega) = -\frac{N_e}{\omega(\omega + i\tau_e)}$ with $\omega_p = \sqrt{\frac{N_e e^2}{\epsilon_{\infty} m^*}}$
- **Valence electrons**[1,2]: Interband transitions $E_0, E_1, E_1+\Delta_1, E_0', E_2, E_1'$
 $E_0, E_0+\Delta_0: \epsilon^{(VE,0)}(E) = A_0 E^{-2} [c_0^2 - (1+c_0)^{0.5} - (1-c_0)^{0.5}]$ with $c_0 = [E + i\tau]/E_0$
 $E_1, E_1+\Delta_1: \epsilon^{(VE,1)}(E) = -A_1 c_1^{-2} \ln(1-c_1^2)$ plus: excitonic contributions to E_1 and $E_1+\Delta_1$, due to Lorentzian lineshapes
 $E_0', E_2, E_1':$ Damped harmonic oscillators

[1] S. Adachi, Physical Properties of III-V Semiconductor Compounds (Wiley, New York, 1992); [2] C. W. Higgins and others, Phys. Rev. 184, 521 (1969)